

Integration and localized growth of metal-oxide nanowires for low power gas-sensing applications

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Motivation

- *Development of high sensitivity, low cost and/or low power consumption solid state gas sensors for safety and control applications*

✓ Chemical sensors world market **US\$12 billion** by 2008

⇒ metal oxide sensors only 15% of market (2008)

Source: Global Industry Analysts "Sensors: A Global Strategic Business Report"

✓ Active field in R&D: looking for a **better performance** keeping **cost down**

Better performance?

1. Sensitivity
2. Stability
3. Response time
4. Working temperature
5. Selectivity
6. Power consumption
7. Integration
8. Mass production ...

Use of nanowires

UV-activated sensors

E-nose (sensor matrix)

Microhotplates; self-heating

Alignment of nanowires

Parallel processing

In-situ growth

Outline

1. Operation principle of MOX nanowire-based gas sensors

2. Gas sensors based one Single Nanowires

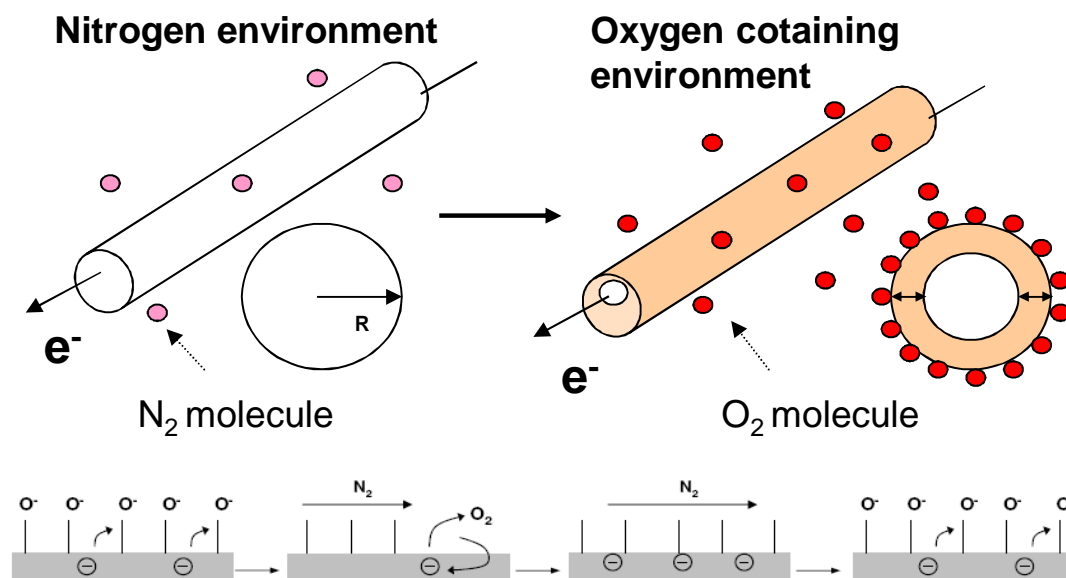
3. Microhotplates: towards low power consumption devices

4. Microhotplates: microlaboratories for materials' growth

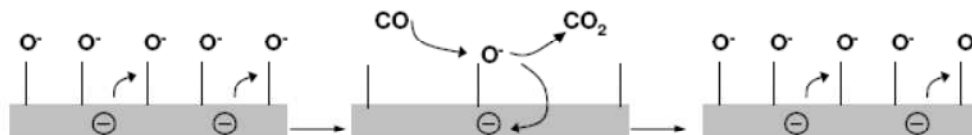
5. Conclusions

1. MOX NW-based gas sensors

Synthetic Air/Nitrogen (oxidising atmosphere) ($T > 200\text{ }^{\circ}\text{C}$)



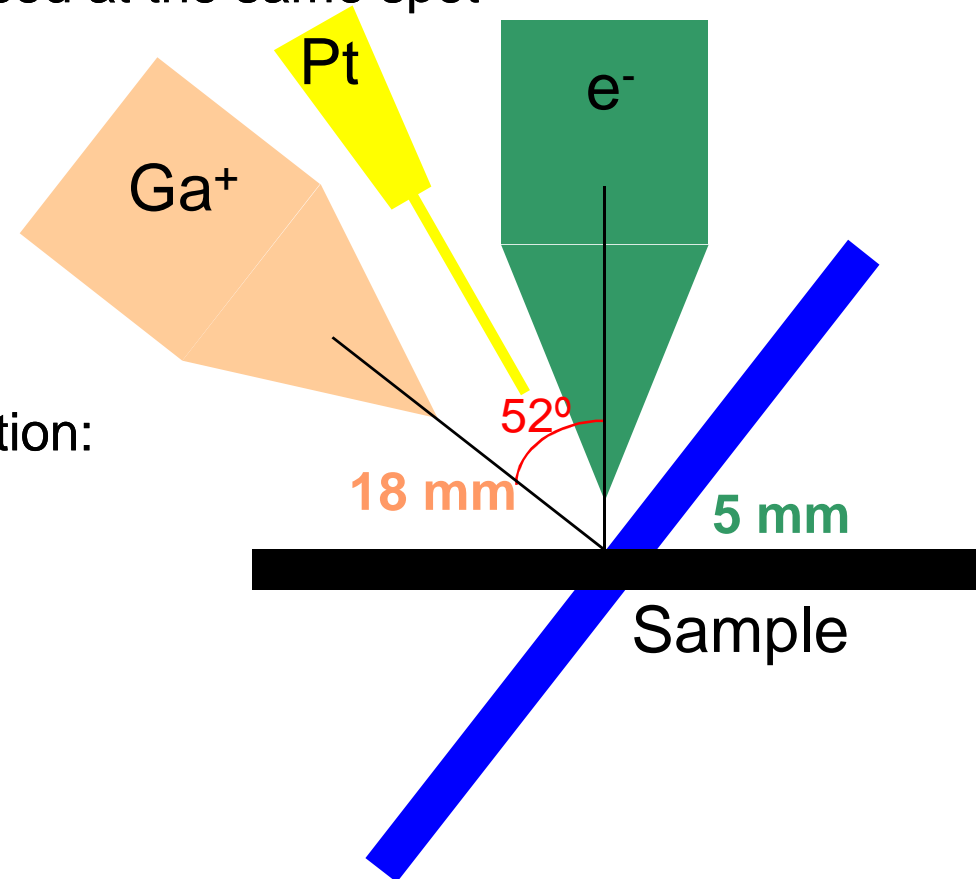
Carbon monoxide (reducing gas)



2. Fabrication of the gas sensors

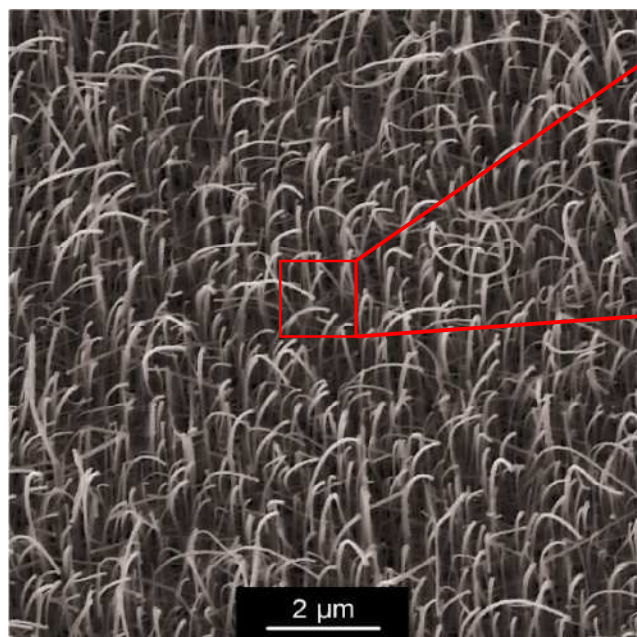
Dual beam focused ion beam machine (FEI Strata DB 235)

- 2 beams: electrons and ions, focused at the same spot
- Electrons: FEG 0.5-30kV
- Ions (Ga^+): 30 kV, 1pA-20nA
Projected range (in Si): 26 nm
- Minimum ion beam size: 6 nm
- Metallorganic precursor for deposition:
 $\text{PtC}_9\text{H}_{16}$
- Both electron and ion-assisted deposition can be performed

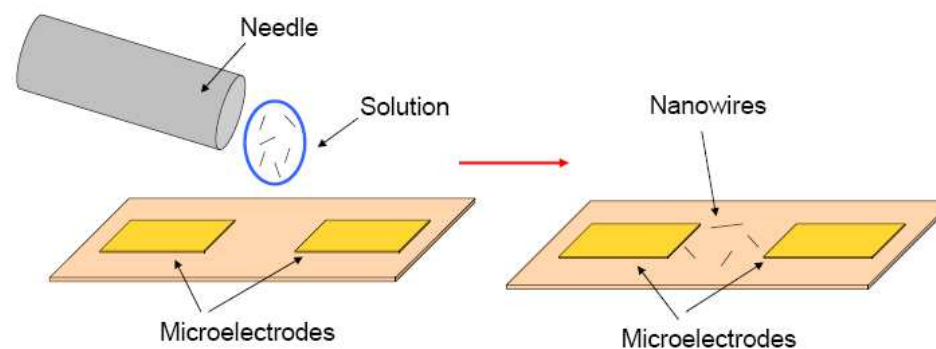
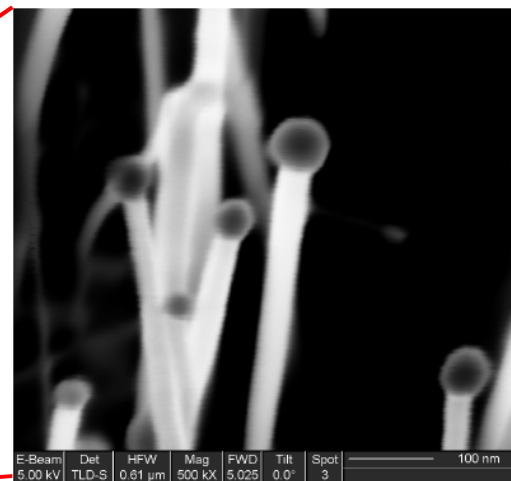


2. Fabrication of the gas sensors

Nanowires are dispersed over a substrate with pre-patterned microelectrodes:



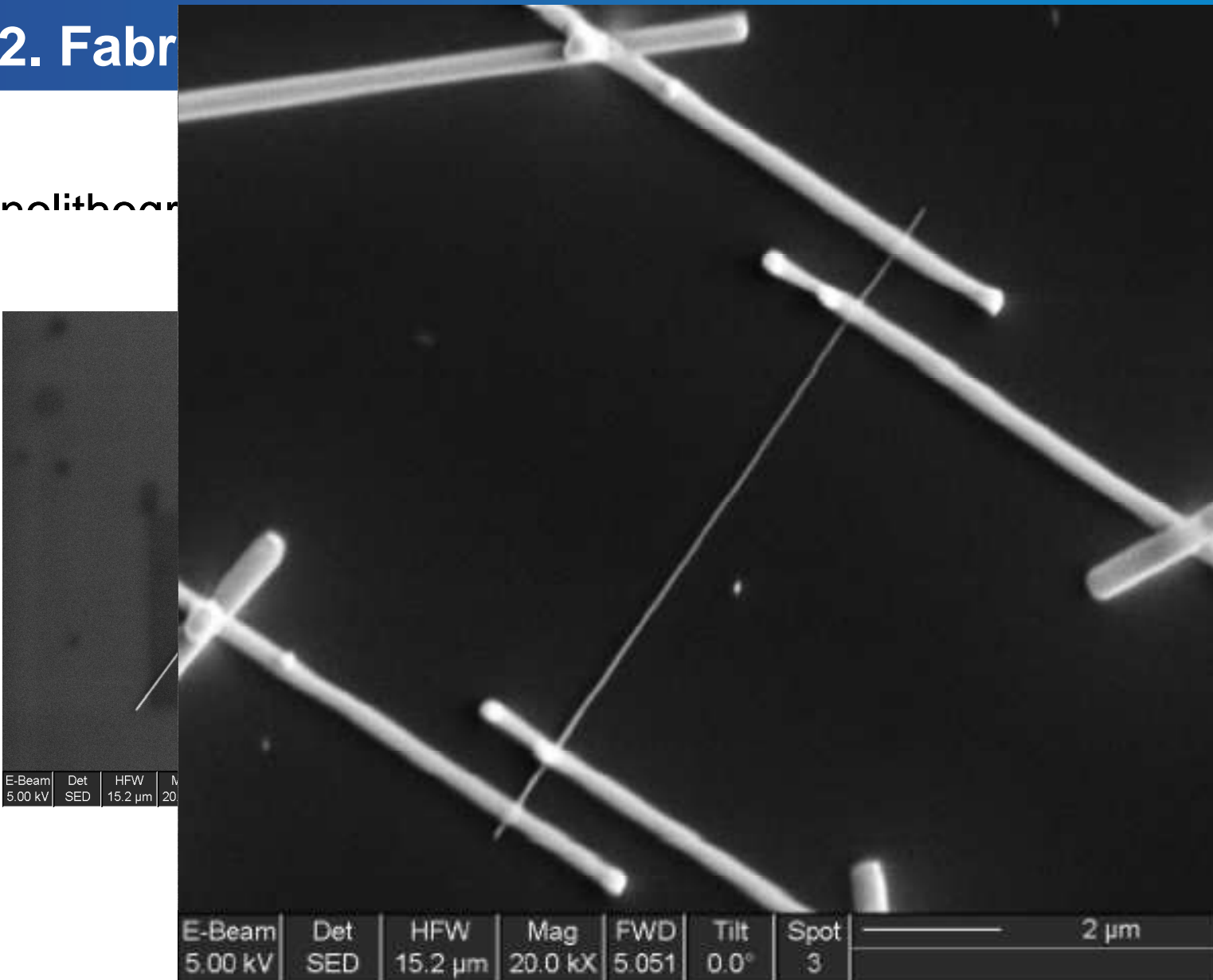
SnO₂ Nanowires



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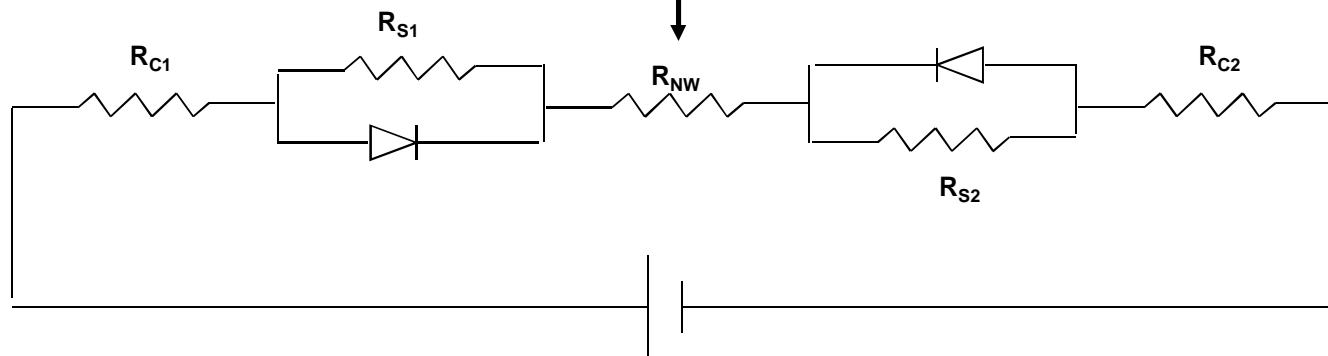
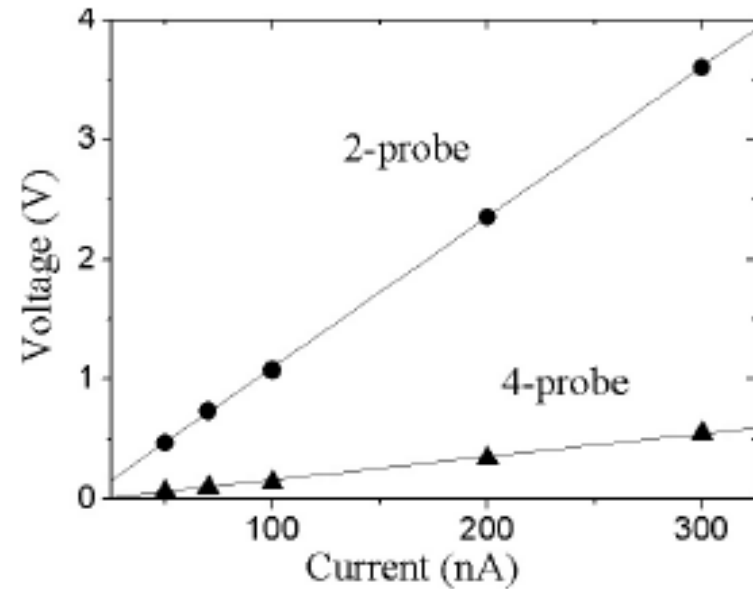
Nanotechnology 17, 5577-5583 (2006)

2. Electrical testing of the devices

Electrical Characterisation (2&4 probing)

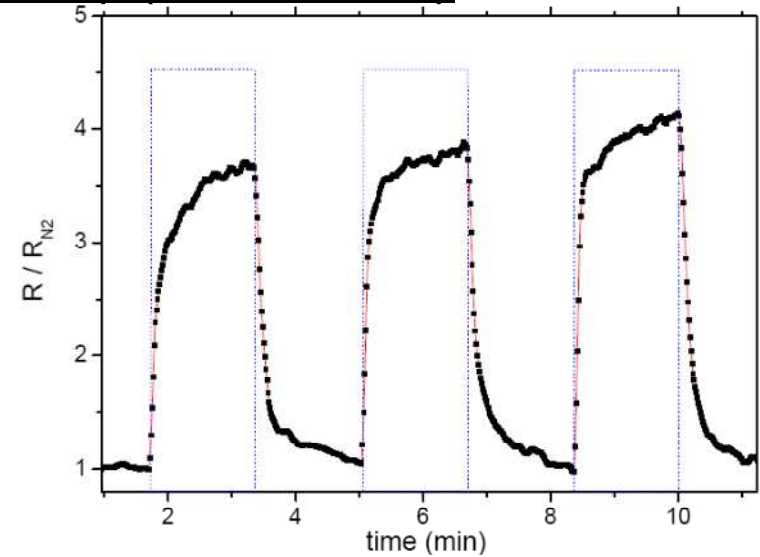
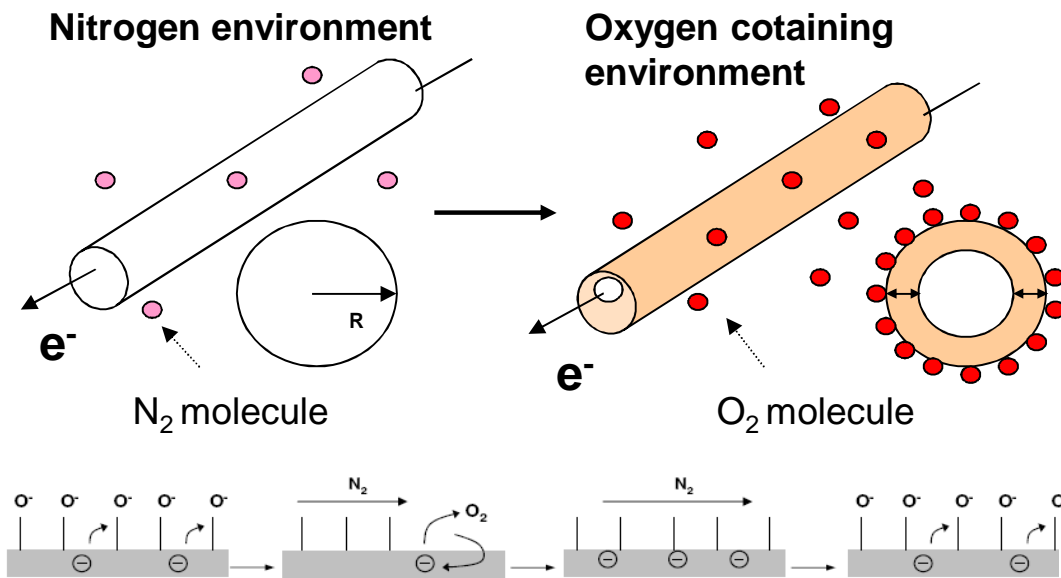
Semiconductor
nanowires

- Mostly not ohmic responses
- High contact resistances
- Study of the NW requires 4p-p
- Self-heating at contacts

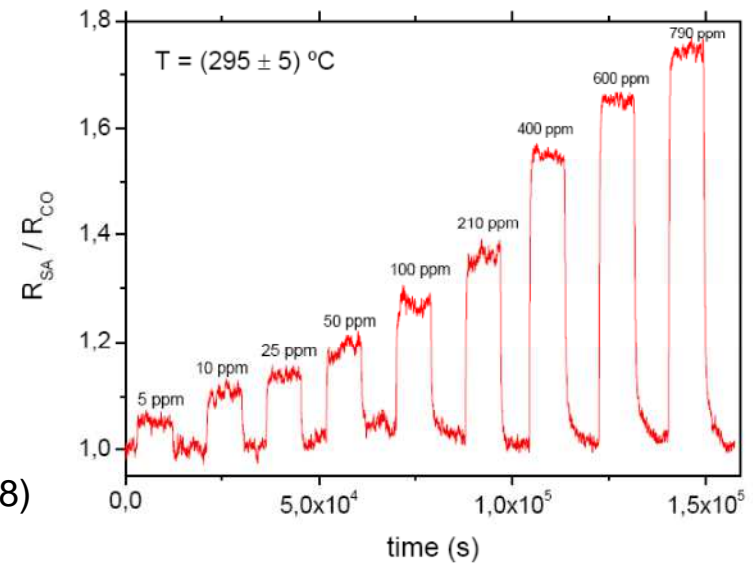
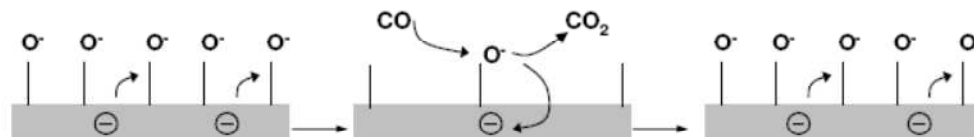


2. Gas Sensor Measurements

Synthetic Air/Nitrogen (oxidising atmosphere) ($T > 200\text{ }^\circ\text{C}$)

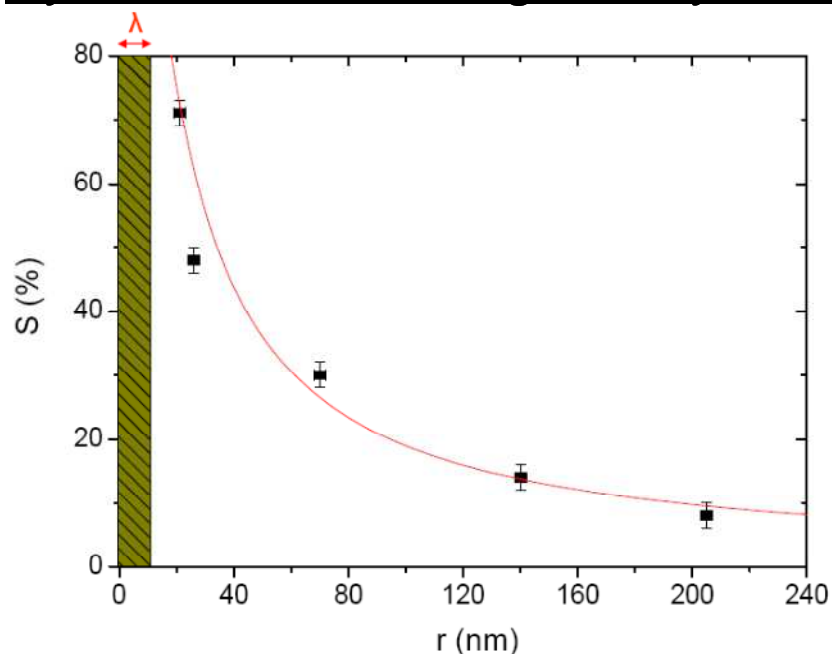


Carbon monoxide (reducing gas)



2. Gas Sensor Measurements

Synthetic Air / Nitrogen / Synthetic Air ($T > 200\text{ }^{\circ}\text{C}$)



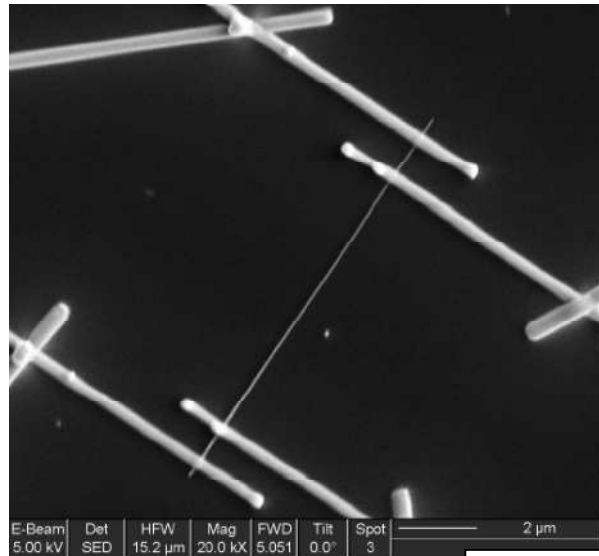
- Higher responses with thinner nanowires
- Raise surface / volume ratio
- Depleted region $W = 10\text{ nm}$

Target Gases	Concentration range	Sensitivity $R_{NW}(\text{gas})/R_{NW}(\text{SA})$	Response time
O ₂	0.5ppm – 2·10 ⁵ ppm	0.4 @ 10 ³ ppm	< 10min @ 270°C
NO ₂	0.1ppm – >10ppm	1.3 @ 1 ppm	< 1min @ 180°C
CO	50 – >1000ppm	0.88 @ 100 ppm	< 1min @ 300°C
EtOH	10 – 1000ppm	0.1 @ 100ppm	< 1min @ 175°C
H ₂ O	2500ppm – 30000ppm	0.6 @ 8000ppm	< 10min @ 295°C

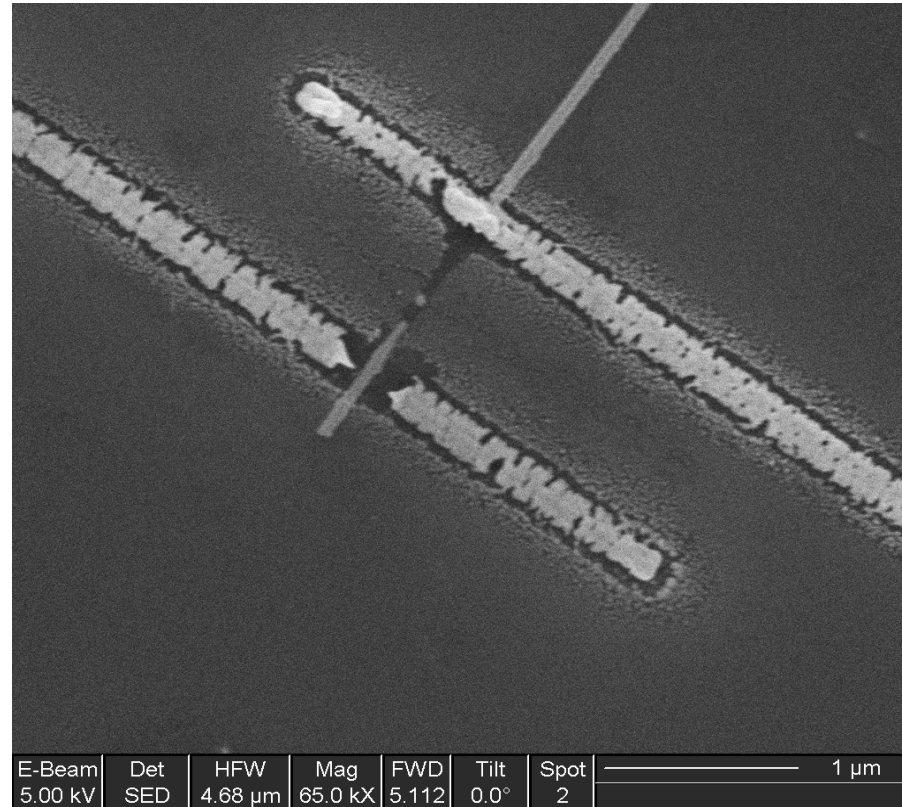
2. Gas Sensor Measurements

Electrical Characterization (self heating)

Negative effects



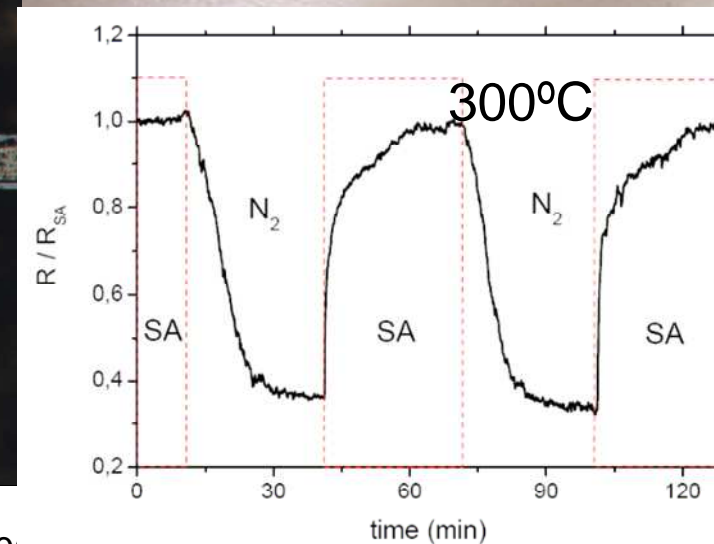
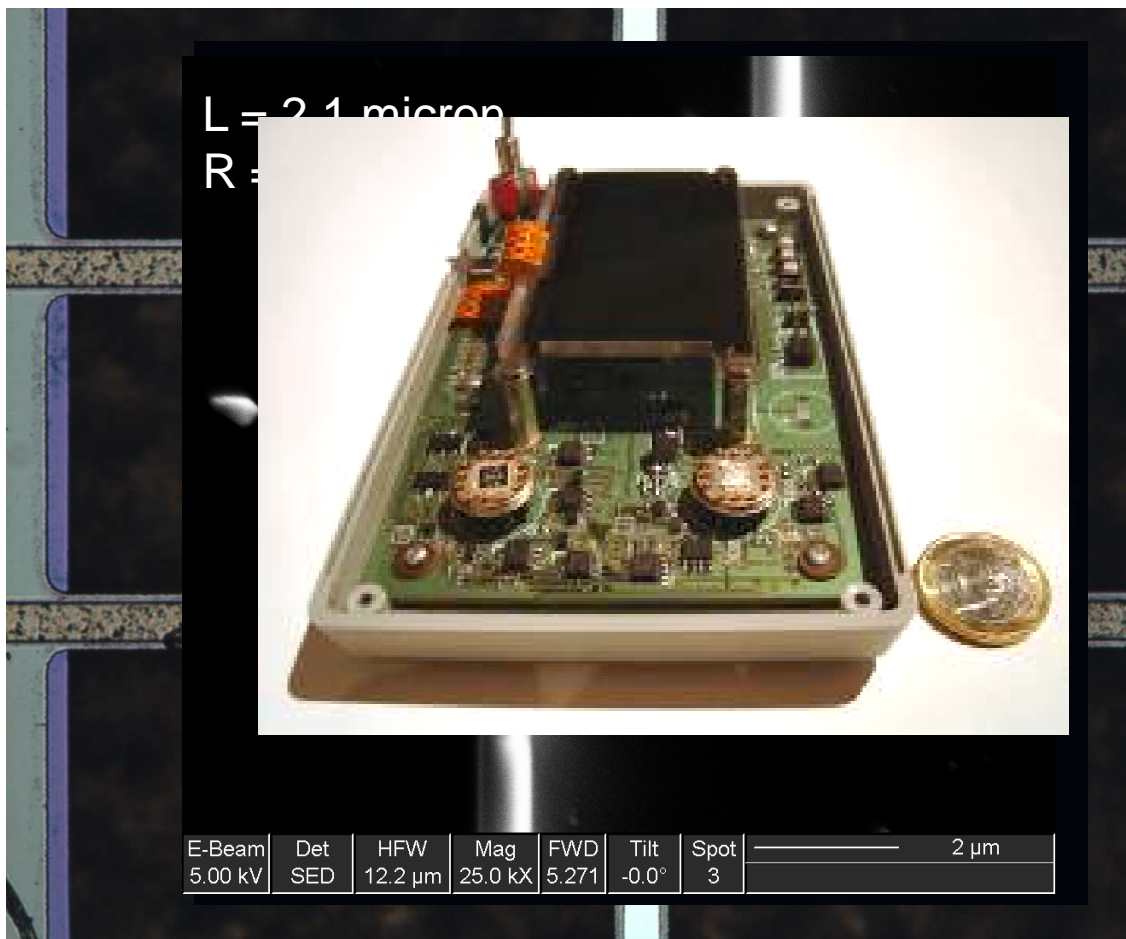
$T = 298\text{ K}$
 $V = 4\text{ V}$
 $I = 21,62\text{ nA}$
 $R = 185\text{ M}\Omega$
 $R_{NW} = 76\text{ M}\Omega$
 $R_{SI} = 109\text{ M}\Omega$



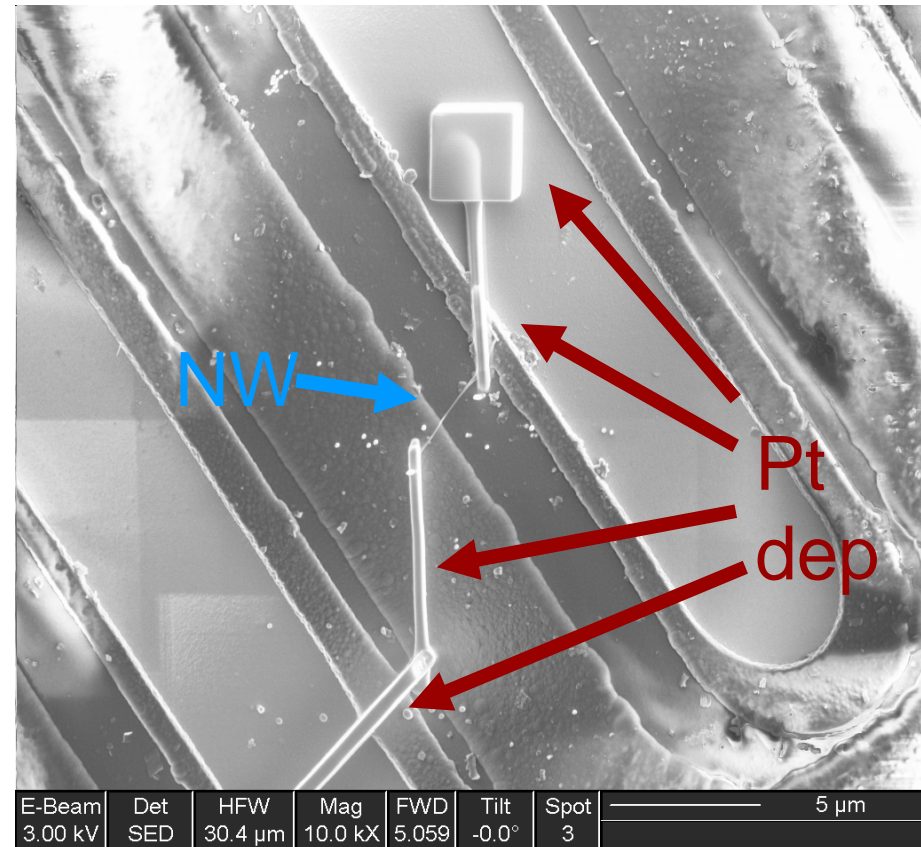
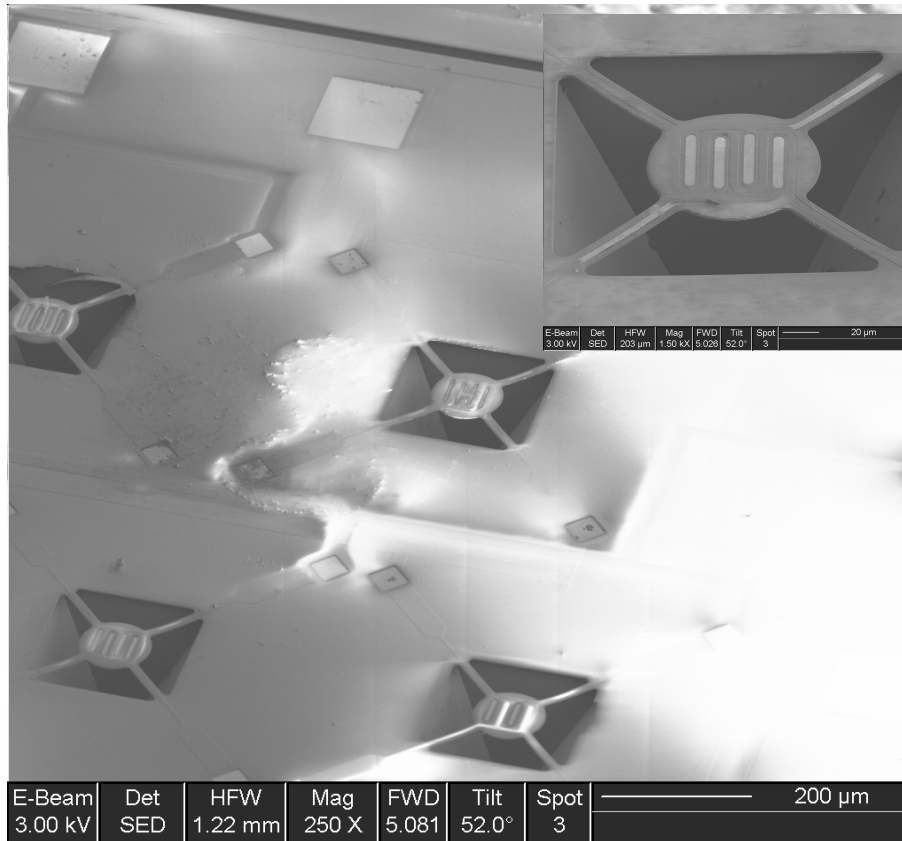
But things are not so bad ...
if one is careful: controlled heating

3. Microhotplates for lower power consumption

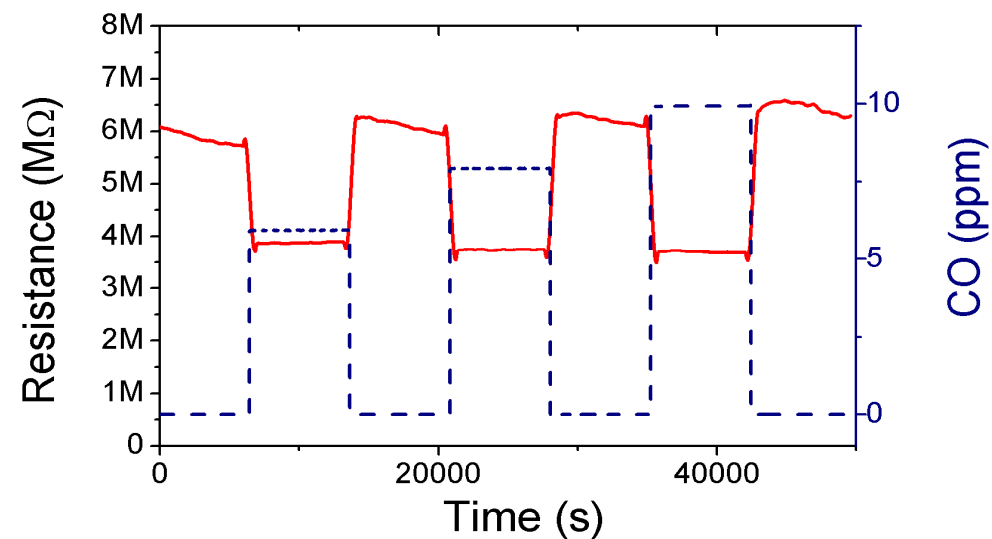
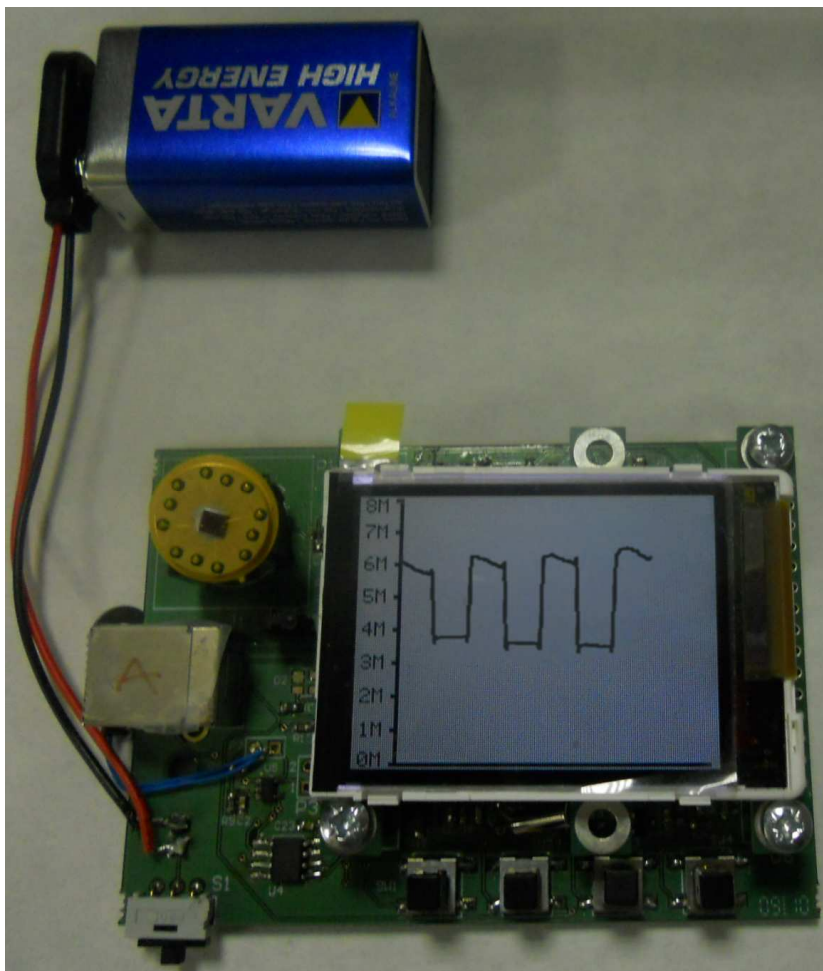
Contact fabrication on suspended microhotplates with integrated heater



3. Microhotplates for lower power consumption

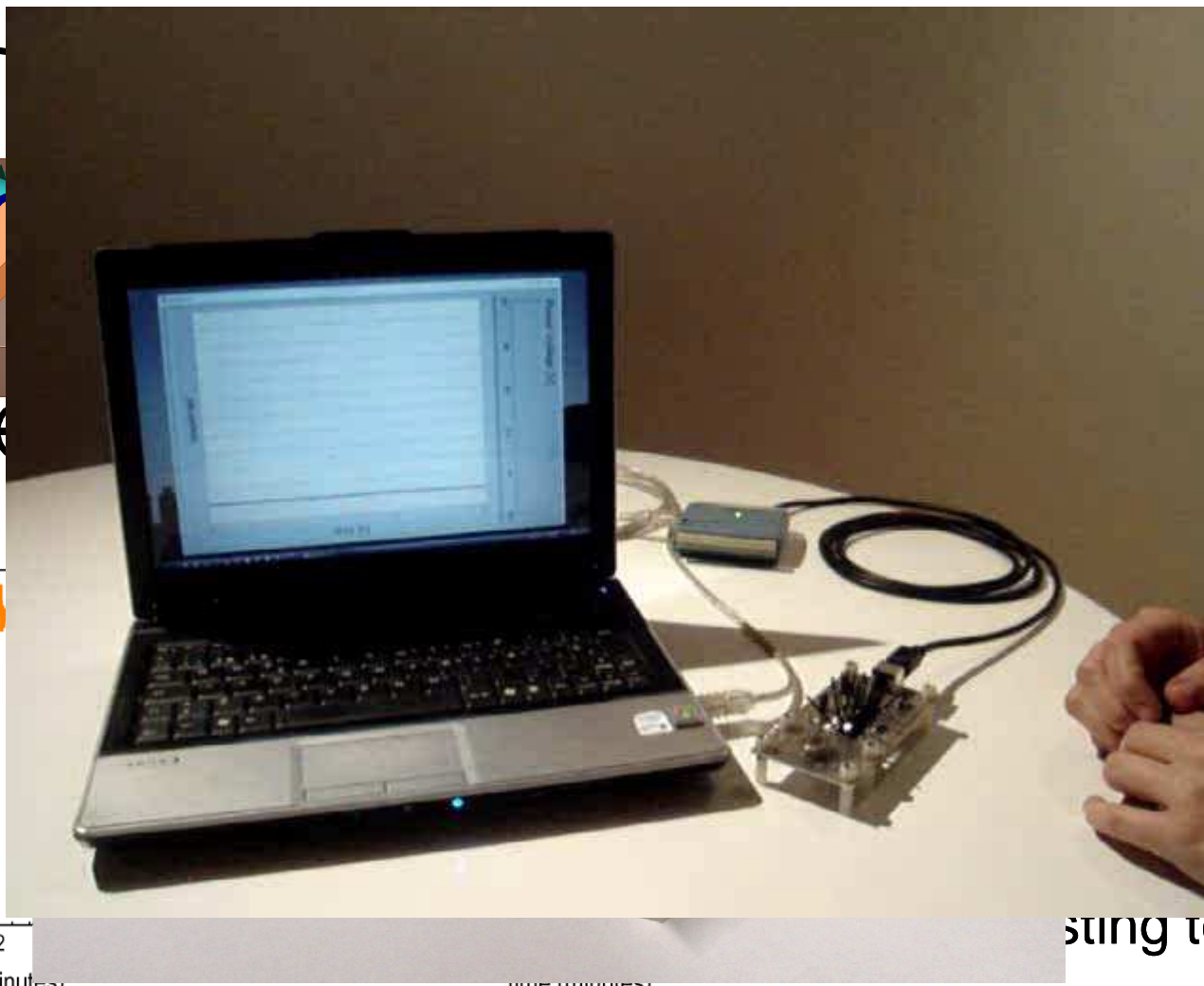
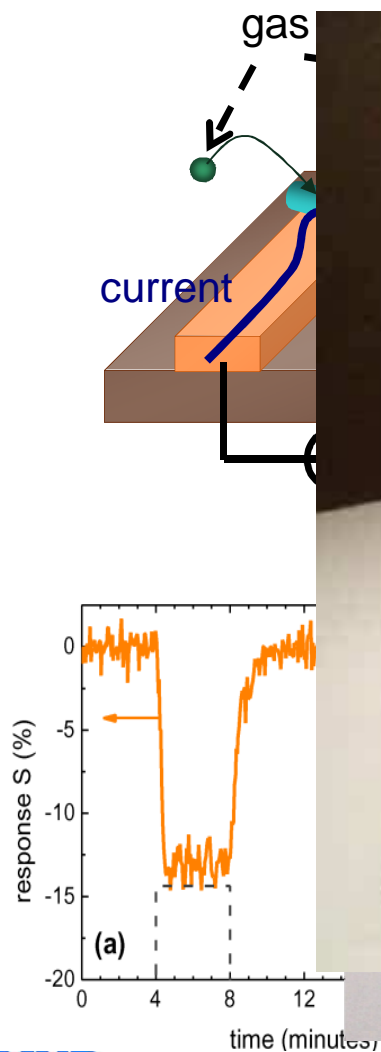


3. Microhotplates for lower power consumption



Operative gas sensor system based on nano-technologies.

3. Microhotplates for self-heated devices



and signal
quires only

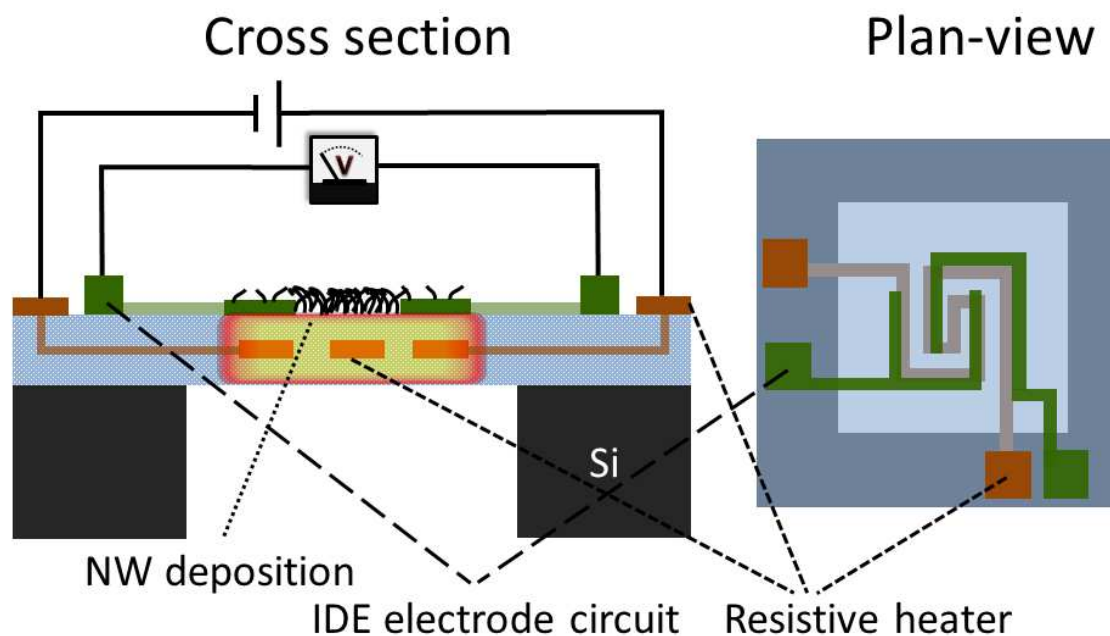
with energy
sting techniques



Applied Physics Letters 93, 123110 (2008)

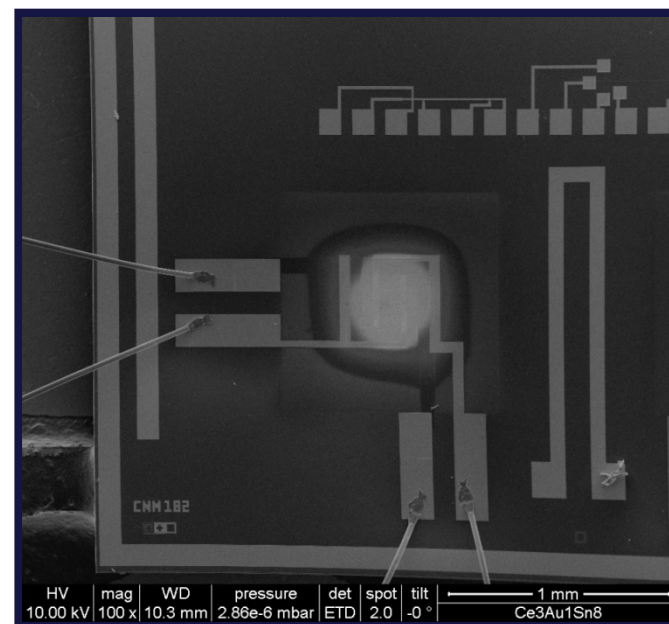
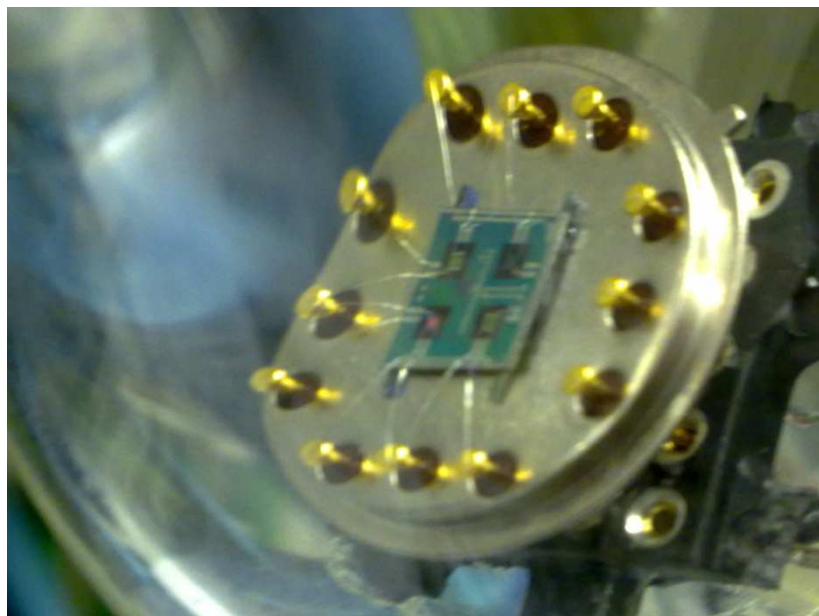
4. In-situ growth and integration on microhotplates

Motivation: use of the microhotplates with integrated heater for in-situ growth and integration of NWs

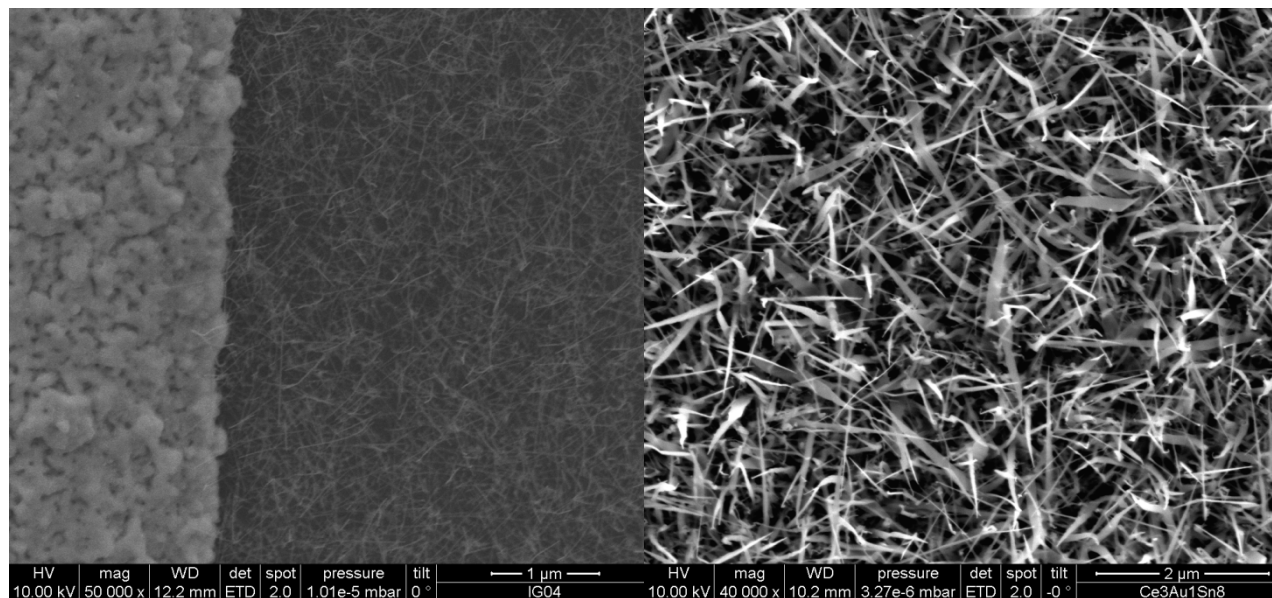


4. In-situ growth and integration on microhotplates

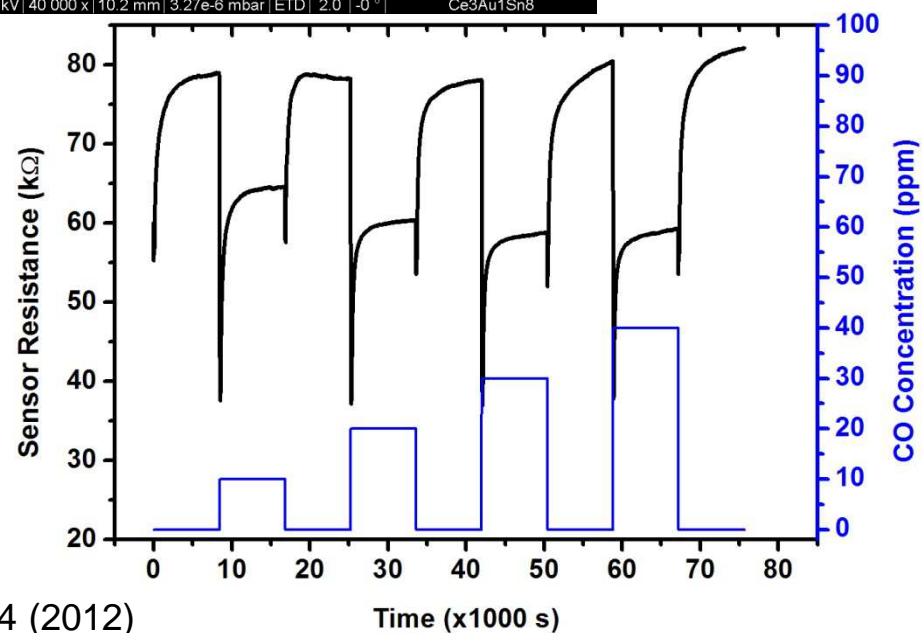
Membranes with polySi heater fabricated using bulk micromachining



4. In-situ growth and integration on microhotplates



Efficient growth of single-crystal SnO₂ NWs and high response to CO



5. Conclusions

- Single NWs are electrically contacted with the help of FIB lithography techniques
- Gas nanosensors based on individual NWs with improved properties can be fabricated with this technology
- Extension of the technology to suspended microhotplates for low power consumption
- Controlled self-heating can be used for ultralow power devices
- In-situ growth and integration of NWs has been demonstrated

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